L Number	Hits	Search Text	DB	Time stamp
3	491	((sulfuric or sulphuric) adj acid) and (water adj drop)	USPAT;	2003/11/15 13:06
		1	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
		(//sulfusions sulphusis) adicaid) and (water adi dean)) and (/water	IBM_TDB	0000/44/45 40:07
6	2	/ ///	USPAT;	2003/11/15 13:07
	İ	adj drop) with (storage))	US-PGPUB;	
			EPO; JPO; DERWENT;	
			IBM_TDB	
9	1985	134/100.1,107,111,182.ccls.	USPAT;	2003/11/15 13:30
"			US-PGPUB:	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	i ·
10	151	134/100.1,107,111,182.ccls. and 134/902.ccls.	USPAT;	2003/11/15 13:29
}			US-PGPUB;	
			EPO; JPO;	
		·	DERWENT;	
11	4	(134/100.1,107,111,182.ccls. and 134/902.ccls.) and (acid with	IBM_TDB USPAT;	2003/11/15 13:29
''	"	(regenerat\$3 or recycl\$3))	US-PGPUB;	2003/11/13 13.29
		1.030	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
12	· 13	134/100.1,107,111,182.ccls. and (acid with (regenerat\$3 or	USPAT;	2003/11/15 13:30
		recycl\$3))	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
13	3871	134/100.1,107,111,182,902.ccls.	IBM_TDB USPAT;	2002/11/15 12:20
13	3071	134/100.1,107,111,102,902.0015.	US-PGPUB;	2003/11/15 13:30
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
14	28	134/100.1,107,111,182,902.ccls. and (acid with (regenerat\$3 or	USPAT;	2003/11/15 13:31
		recycl\$3))	US-PGPUB;	
			EPO; JPO;	
·			DERWENT; IBM TDB	
	277	134/\$.ccls. and (sulfuric adj acid) and recycl\$3	USPAT;	2003/11/14 14:16
		The state of the s	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	14	(134/\$.ccls. and (sulfuric adj acid) and recycl\$3) and ((sulfuric adj	USPAT;	2003/11/04 17:07
		acid) with recycl\$3)	US-PGPUB;	
			EPO; JPO;	
			DERWENT; IBM TDB	
_	186	((sulfuric adj acid) with recycl\$3).ti.	USPAT:	2003/11/04 17:07
		(1	US-PGPUB;	=555/1/104 17.07
			EPO; JPO;	
			DERWENT;	
	!		IBM_TDB	
-	10	(((sulfuric adj acid) with recycl\$3).ti.) and peroxide	USPAT;	2003/11/04 17:08
			US-PGPUB;	
			EPO; JPO;	
	Į		DERWENT; IBM TDB	
	1348	(sulfuric adj acid) and recycl\$3 and peroxide and (wafer or	USPAT;	2003/11/04 17:10
		semiconductor or substrate)	US-PGPUB;	=000,71704 17.10
		,	EPO; JPO;	
	ļ		DERWENT;	
			IBM TDB	

-	1160	((sulfuric adj acid) and recycl\$3 and peroxide and (wafer or semiconductor or substrate)) and heat\$3	USPAT; US-PGPUB; EPO; JPO;	2003/11/04 17:14
			DERWENT; IBM TDB	
-	85	(((sulfuric adj acid) and recycl\$3 and peroxide and (wafer or	USPAT;	2003/11/14 16:21
		semiconductor or substrate)) and heat\$3) and aspirat\$3	US-PGPUB; EPO; JPO;	
			DERWENT;	
<u> </u>	5	((((sulfuric adj acid) and recycl\$3 and peroxide and (wafer or	IBM_TDB   USPAT;	2003/11/04 17:19
		semiconductor or substrate)) and heat\$3) and aspirat\$3) and	US-PGPUB;	2000/11/04 17:10
		((purify or purification or recycl\$3 or regenerat\$3) with (sulfuric adj acid))	EPO; JPO; DERWENT;	
	270		IBM_TDB	0000/44/44 44 40
-	279	134/\$.ccls. and ((sulfuric or sulphuric) adj acid) and recycl\$3	USPAT; US-PGPUB;	2003/11/14 14:16
			EPO; JPO;	
			DERWENT;	
-	124	134/100.0,107,111,182.ccls. and 134/902.ccls.	USPAT;	2003/11/15 13:29
			US-PGPUB; EPO; JPO;	
			DERWENT; IBM_TDB	
-	3	(134/100.0,107,111,182.ccls. and 134/902.ccls.) and (acid with	USPAT;	2003/11/15 13:30
		(regenerat\$3 or recycl\$3))	US-PGPUB; EPO; JPO;	
			DERWENT;	
-	925	134/111.ccls.	IBM_TDB USPAT;	2003/11/14 16:23
			US-PGPUB;	
			EPO; JPO; DERWENT;	
	12	134/111.ccls. and ((sulfuric or sulphuric) adj acid)	IBM_TDB USPAT;	2003/11/14 16:23
	'-	104/11 1.0013. and ((Sulfatile of Sulphullo) adj acid)	US-PGPUB;	2003/11/14 10.23
			EPO; JPO; DERWENT;	
	4460	(//aulfusia an aulahusia) adi adid utih (	IBM_TDB	
-	4469	(((sulfuric or sulphuric) adj acid) with (regenerat\$3 or recycl\$3))	USPAT; US-PGPUB;	2003/11/14 16:25
			EPO; JPO;	
			DERWENT; IBM_TDB	
-	430	((((sulfuric or sulphuric) adj acid) with (regenerat\$3 or recycl\$3))) and (wafer or semiconductor or substrate)	USPAT; US-PGPUB;	2003/11/14 16:25
		( See Commence of Substitute)	EPO; JPO;	
			DERWENT; IBM TDB	
-	329	(((((sulfuric or sulphuric) adj acid) with (regenerat\$3 or recycl\$3)))	USPAT;	2003/11/14 16:26
		and (wafer or semiconductor or substrate)) and heat\$3	US-PGPUB; EPO; JPO;	
		•	DERWENT; IBM_TDB	
-	11	((((((sulfuric or sulphuric) adj acid) with (regenerat\$3 or	USPAT;	2003/11/14 16:31
		recycl\$3))) and (wafer or semiconductor or substrate)) and heat\$3) and 134/\$.ccls.	US-PGPUB; EPO; JPO;	
		. , ===================================	DERWENT;	
_	27	"Yasuda, Okimitsu"	IBM_TDB USPAT;	2003/11/14 16:53
			US-PGPUB;	
		•	EPO; JPO; DERWENT;	
			IBM_TDB	

-	77	"Fujii, Seiichi"	USPAT; US-PGPUB;	2003/11/14 16:53
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	4	"Fujii, Seiichi" and (sulfuric or sulphuric)	USPAT;	2003/11/14 16:54
			US-PGPUB; EPO; JPO;	
			DERWENT;	
			IBM TDB	
-	2	"Fujii, Seiichi" and (recycl\$3)	USPAT;	2003/11/14 16:54
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	11	134/100.0,107,111,182.ccls. and (acid with (regenerat\$3 or	IBM_TDB   USPAT;	2003/11/15 13:30
-	''	recycl\$3))	US-PGPUB;	2003/11/13 13.30
1		100)0140//	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	3		USPAT;	2003/11/14 17:00
		aspirat\$3))	US-PGPUB; EPO; JPO;	
		·	DERWENT:	
			IBM TDB	
-	360	(((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3))	USPAT;	2003/11/14 17:09
			US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
_	24	((((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3))) and	IBM_TDB USPAT;	2003/11/14 17:07
	-	((recycl\$3 or regenerat\$3) with acid)	US-PGPUB;	2003/11/14 17.07
			EPO; JPO;	
			DERWENT;	
-X-	70	/ ///outstance outstance of sold with /outstance outstance (#2)\\	IBM_TDB	0000444444707
-	78	((((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3))) and ((distill\$5 or recycl\$3 or regenerat\$3) with acid)	USPAT; US-PGPUB;	2003/11/14 17:07
		((distilled of recycles of regellerates) with acidy	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	77	(( (((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3)))	USPAT;	2003/11/14 17:08
		and ((distill\$5 or recycl\$3 or regenerat\$3) with acid)) and water	US-PGPUB;	
			EPO; JPO; DERWENT;	
		•	IBM TDB	
-	17	(((sulfuric or sulphuric) adj acid) with (suction or aspirat\$3) with	USPAT;	2003/11/14 17:15
		distill\$5)	US-PGPUB;	
			EPO; JPO;	
			DERWENT; IBM_TDB	
-	2575	(((sulfuric or sulphuric) adj acid) with (water) with distill\$5)	USPAT;	2003/11/14 17:25
		(11)	US-PGPUB;	
		·	EPO; JPO;	
			DERWENT;	
	1125	(((culturio or culphurio) adi poid) with (water) with distill@E\\ ===	IBM_TDB	2002/14/44 47:42
	1120	( (((sulfuric or sulphuric) adj acid) with (water) with distill\$5)) and (suction or vacuum)	USPAT; US-PGPUB;	2003/11/14 17:12
		122222. 2. 10000111)	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
-	76	(((sulfuric or sulphuric) adj acid) with (water) with distill\$5 with	USPAT;	2003/11/14 17:12
		(aspirat\$3 or vacuum or suc\$4))	US-PGPUB; EPO; JPO;	
			DERWENT;	
			IBM_TDB	

		•		
-	3149	((sulfuric or sulphuric) adj acid) near3 (distill\$5 or recycl\$3 or regenerat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/11/14 17:16
-	17	((sulfuric or sulphuric) adj acid) near3 (distill\$5 or recycl\$3 or regenerat\$3) with (water) with (aspirat\$3 or vacuum or suction)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/14 17:20
-	21	((sulfuric or sulphuric) adj acid) near4 (distill\$5 or recycl\$3 or regenerat\$3) with (water) with (aspirat\$3 or vacuum or suction)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/14 17:21
•	9	((sulfuric or sulphuric) adj acid) with (distill\$5 or recycl\$3 or regenerat\$3) with (water) with (aspirat\$3 or vacuum or suction) with heat\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/14 17:21
-	162	(((sulfuric or sulphuric) adj acid) near (distill\$5 or recycl\$3 or regenerat\$3)).ti.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/14 17:25
-	4	((((sulfuric or sulphuric) adj acid) near (distill\$5 or recycl\$3 or regenerat\$3)).ti.) and (vacuum or aspirat\$3 or suc\$4)	USPAT	2003/11/14 17:26